

HBS Special Session <The speakers will be announced shortly.>

	Room A
13:00	
13:10	
13:40	
14:10	
14:40	

	Room A
15:10	
15:30	
16:00	
16:30	

	Room A	Room B	Room C	Room D	Room E	Room F
9:00	<b>15WA1: INEMI</b> <b>15WA1-1</b> Testing and Characterization for Semiconductor Packaging Thermal Management Dongkai Shangguan <sup>1</sup> , Chun Keang Ooi <sup>2</sup> , Sze Pei Lim <sup>1</sup> , <sup>1</sup> Indium Corporation, <sup>2</sup> Intel, <sup>3</sup> Thermal Engineering Associates, Inc. <b>15WA1-2</b> Benchmarking AOI Capabilities for Fine Pitch Substrate Inspection Feng Xue <sup>1</sup> , Charles Reynolds <sup>2</sup> , Glenn Pomerantz <sup>2</sup> , Jason Frankel <sup>2</sup> , Thomas Wassick <sup>2</sup> , Charlie Zhu <sup>2</sup> , Masahiro Tsuruya <sup>2</sup> , <sup>1</sup> IBM, <sup>2</sup> IBM Corp, <sup>3</sup> Nordson T&L, <sup>4</sup> INEMI <b>15WA1-3</b> Thermal Stress Study of Low Temperature Material for 1st Level Interconnect Sze Pei Lim <sup>1</sup> , Danyang Zheng <sup>1</sup> , Russell Kastberg <sup>2</sup> , Shripad Gokhale <sup>2</sup> , Yasuharu Yamada <sup>2</sup> , Masaki Sanada <sup>2</sup> , Takumi Miyazaki <sup>2</sup> , Kei Murayama <sup>2</sup> , Masahiro Tsuruya <sup>2</sup> , <sup>1</sup> Indium Corporation, <sup>2</sup> IBM Infrastructure, <sup>3</sup> Intel Corporation, <sup>4</sup> IBM Research, <sup>5</sup> Shinko Electric Industries, <sup>6</sup> INEMI <b>15WA1-4</b> Warpage Experiments and Simulation for Glass Core Substrate Kang Eu Ong <sup>1</sup> , Konishi Junko <sup>2</sup> , Satake Noboru <sup>2</sup> , Sato Yoichiro <sup>2</sup> , Yoshida Tatsuro <sup>2</sup> , Murayama Kei <sup>2</sup> , Tsukahara Makoto <sup>2</sup> , Haley Fu <sup>2</sup> , <sup>1</sup> Intel Technology, <sup>2</sup> AGC, <sup>3</sup> Shinko, <sup>4</sup> Inemi	<b>15WB1: EPTC</b> <b>15WB1-1 &lt;Session Invited&gt;</b> TBD <b>15WB1-2 &lt;Session Invited&gt;</b> TBD <b>15WB1-3 &lt;Session Invited&gt;</b> TBD <b>15WB1-4 &lt;Session Invited&gt;</b> TBD	<b>15WC1: Fanout Packing-1</b> <b>15WC1-1</b> Advanced Panel Level Fan Out Package - Development of a Damascene Integration Scheme for Cu Redistribution Layers Eungchul Kim, Suhyeon Jeon, Jusuk Kang, Sanghoon Cho, Jeongmin Seo, Dongjeon Oh, Juil Choi, Minwoo Rhee, Samsung Electronics <b>15WC1-2</b> From Pilot To HVM A Practical Overlay Yield Prediction Workflow For FOPLP Lithography John Chang, Jian Lu, Timothy Chang, Onto Innovation <b>15WC1-3</b> TRC and Fusing current Characterization of Cu RDL Lines for Fan-Out Wafer-Level Packaging Fayong Liu <sup>1</sup> , Jinbiao Hu <sup>1</sup> , I-Hung Lin <sup>2</sup> , Maple Jiang <sup>3</sup> , Jinyan Nan <sup>1</sup> , Ryan Pang <sup>3</sup> , Dongdong Niu <sup>1</sup> , Yinhan Zhao <sup>1</sup> , Qianyu Jia <sup>1</sup> , Kaiqi Sun <sup>1</sup> , Haiyong Zheng <sup>1</sup> , Tom Ni <sup>2</sup> , <sup>1</sup> Ocean University of China, <sup>2</sup> Kore Semiconductor Co., Ltd <b>15WC1-4</b> Approach of graphic dynamic adjustment integrate to Laser direct imaging solution on 600um Panel Fan Out PING CHING Shen, Jen-Kuang Fang, Ping-Feng Yang, Sheng-Feng Huang, Advanced Semiconductor Engineering, Inc.	<b>15WD1: HB Process</b> <b>15WD1-1 &lt;Session Invited&gt;</b> TBD <b>15WD1-2 &lt;Session Invited&gt;</b> TBD <b>15WD1-3</b> Simplified Gap-Filling Process for Reconstructed Die-to-Wafer Hybrid Bonding Using Spin-Coated Silicone Resin Asuka Fujii <sup>1,2</sup> , Yutetsu Kamiya <sup>1</sup> , Kenta Hayama <sup>1</sup> , Fumihiro Inoue <sup>2</sup> , <sup>1</sup> Yokohama National University, <sup>2</sup> ADEKA Corporation <b>15WD1-4</b> Prediction of High-Temperature Expansion of Cu in SiO2 Vias for Fine-Pitch Hybrid Bonding 3D-IC Applications Pin-Lin Chen <sup>1</sup> , Chih Chen <sup>1,2</sup> , <sup>1</sup> Institute of Pioneer Semiconductor Innovation, National Yang Ming Chiao Tung University, <sup>2</sup> Department of Materials Science and Engineering, National Yang Ming Chiao Tung University	<b>15WE1: Materials-1</b> <b>15WE1-1</b> Electro-Plating of Sn-Cu-Ni Based IMC Material for Connectors and Switches Hiroaki Ikeda, Shigenobu Sekine, Napra, Co. Ltd. <b>15WE1-2</b> Cu3Sn as a Passivation Layer for Improving Reliabilities of Nanotwinned Cu Interconnects Jing Chok, Chih Chen, Yi-Quan Lin, National Yang Ming Chiao Tung University <b>15WE1-3</b> Strengthening of Pressureless Ag Sintering with (111)-Oriented Nanotwinned Cu Substrate Zhi-Quan Liu <sup>1</sup> , Shubo Ai <sup>1</sup> , Xingming Huang <sup>2</sup> , <sup>1</sup> Southern Institutes of Science and Technology, <sup>2</sup> Shenzhen Institutes of Advanced Technology, Chinese Academy of Sciences <b>15WE1-4</b> Electric Current Becomes a Thermodynamic Variable - Revisiting Phase Stability in Alloys Shubhayan Mukherjee, Shih-Kang Lin, National Cheng Kung University	<b>15WF1: Emerging Technologies-1</b> <b>15WF1-1 &lt;Session Invited&gt;</b> Proposal of Development of Megawatt Super-Power Operational Amplifier Using Distar Transistor Kensho Okamoto <sup>1</sup> , Ken-ichiro Okamoto <sup>2</sup> , Kazunori Morishita <sup>3</sup> , Atsushi Okuno <sup>4</sup> , <sup>1</sup> Kagawa University, <sup>2</sup> Kyoto University, <sup>3</sup> Green Planets Co. <b>15WF1-2</b> Microstructure Evolution and Strength Improvement in Cu-to-Cu Bonding with Micro/Nano Cu Paste ALBERT TZUCHUA WU <sup>1</sup> , Li-Chen Wu <sup>1</sup> , Shao-Chi Chen <sup>1</sup> , Kelvin Li <sup>2</sup> , Chang-Meng Wang <sup>2</sup> , <sup>1</sup> National Central University, <sup>2</sup> Shenmao Technology INC. <b>15WF1-3</b> Via-Last Bumpless TSV for High Bandwidth NAND (HBN) Koji Sakui, Norio Chujo, Masao Taguchi, Takayuki Ohba, Institute of Science Tokyo <b>15WF1-4</b> Localized plastic deformation analysis of fordable substrates by using micro-digital image correlation Nakyung JEONG <sup>1</sup> , Jeehoon Na <sup>2</sup> , Eunhye Lee <sup>2</sup> , Sojeong Lee <sup>2</sup> , Tae-Ik Lee <sup>2</sup> , Korea Institute of Industrial Technology
10:40	Break					
10:55	<b>15WA2: MEF</b> <b>15WA2-11 &lt;Session Invited&gt;</b> My 40 years with MEMS, leading to mutual contribution of MEMS/Semiconductors Susumu Kaminaga, Toray Industries, Inc./SK Global Advisers Co., Ltd. <b>15WA2-2 &lt;Session Invited&gt;</b> Development of Automotive Chiplet SoC Nobuaki Kawahara, PhD, ASRA, Advanced SoC Research for Automotive <b>15WA2-3 &lt;Session Invited&gt;</b> Compact FT-NIR spectrometer made through MOEMS technology Tomofumi Suzuki, HAMAMATSU PHOTONICS K.K.	<b>15WB2: IMAPS</b> <b>15WB2-1 &lt;Session Invited&gt;</b> TBD <b>15WB2-2 &lt;Session Invited&gt;</b> TBD <b>15WB2-3 &lt;Session Invited&gt;</b> TBD <b>15WB2-4 &lt;Session Invited&gt;</b> TBD	<b>15WC2: Fanout Packing-2</b> <b>15WC2-1</b> A Novel Fan-Out Wafer Module Stacking Technology Using Transfer Bonding Chih-Cheng Hsiao, Industrial Technology Research Institute <b>15WC2-2</b> Warpage Prediction in Multi-Layer Fan-Out Panel-Level Packaging Using Finite Element Method with Artificial Neural Network Chen-Chen Li, Kuo-Shen Chen, National Cheng-Kung University, Department of Mechanical Engineering <b>15WC2-3</b> Advanced Packaging Solution by Large Panel Level Fan-out Process for High Performance Computing application Powei Lu, Jeffrey Yang, Yungshun Chang, Yuan Feng Chiang, Jen Kuang Fang, Advanced Semiconductor Engineering <b>15WC2-4</b> New Advanced Packaging Architecture - CoWoP (Chip on Wafer on Platform PCB) Terry Hsu, Huei-Chi Yang, Sam Lin, Vito Lin, Andrew Kang, Don Son Jiang, Siliconware Precision Industries Co., Ltd.	<b>15WD2: Solder/Intermetallic connect</b> <b>15WD2-1 &lt;Session Invited&gt;</b> Innovative Materials for Advanced Packaging and Heterogeneous Integration Dongkai Shangguan, Sze Pei Lim, Indium Corporation <b>15WD2-2</b> Investigating Interfacial Reactions and Shear Strength of SnAg / Fe-HEA Alloy Tzu-Hsiang Liao <sup>1</sup> , Jia-Xiang Gao <sup>1</sup> , Chuh-Hsiang Liu <sup>1</sup> , Chuan Zhang <sup>2</sup> , Yu-An Shuai <sup>1</sup> , Feng Chia University, <sup>2</sup> CompTherm LLC <b>15WD2-3</b> Interfacial Diffusion Control in Silver-Indium Transient Liquid Phase Bonding with Two-Dimensional Interlayers Jiaqi Song <sup>1</sup> , Donglin Zhang <sup>1</sup> , Xuochen Zhao <sup>1</sup> , Gang Zhang <sup>2</sup> , Yongjun Huo <sup>2,3</sup> , <sup>1</sup> School of Materials Science and Engineering, Beijing Institute of Technology, <sup>2</sup> Yangtze River Delta Graduate School of Beijing Institute of Technology, <sup>3</sup> Shenzhen MSU-BIT University, Department of Materials Science <b>15WD2-4</b> Development and Characterization of Eco-Friendly Sn-Ag-Cu-Zn Solder for Electrical Performance on PCB Applications Andromeda Dwi Laksono <sup>1,2</sup> , Muhammad Ramanda Putra <sup>1</sup> , Nurkholis Majid <sup>1</sup> , Muhammad Mahessa Ajibasa Syaaban <sup>1</sup> , Devit Velanti Putra <sup>1</sup> , Lusi Enawati <sup>1,2</sup> , <sup>1</sup> Muhammad Ridho Devanto <sup>1</sup> , <sup>2</sup> Kharis Sugianto <sup>1</sup> , <sup>3</sup> Study Program of Materials and Metallurgical Engineering, Institut Teknologi Kalimantan, <sup>4</sup> Center for Green Materials Innovation, Institut Teknologi Kalimantan, <sup>5</sup> Department of Chemical Engineering, Institut Teknologi Kalimantan, <sup>6</sup> Department of Electrical Engineering, Institut Teknologi Kalimantan	<b>15WE2: Materials-2</b> <b>15WE2-1</b> Ultra-Thick Photoresist Patterning Enabling Higher Aspect Ratio Cu Posts for Advanced Packaging Tatsuya Fujii, Issei Suzuki, Kazuki Hirano, Eiichi Hayashi, Nobuya Takahashi, Toshiaki Furutani, Takashi Kariya, Samsung Device Solutions R&D Japan, Samsung Japan Corporation <b>15WE2-2</b> Investigation of SiCN-SiCN bonding with different wet pretreatment solutions followed by O2 plasma for Cu/SiCN hybrid bonding application Chien-Yu Liu <sup>1</sup> , Chih Chen <sup>1,2</sup> , Pin-Syuan He <sup>1</sup> , Yun-Hsuan Chen <sup>1</sup> , Rou-Jun Lee <sup>2</sup> , Gyanu Song <sup>2</sup> , Cheng Chieh Kao <sup>2</sup> , <sup>1</sup> Department of Materials Science and Engineering, National Yang Ming Chiao Tung University, <sup>2</sup> Industry Academia Innovation School, National Yang Ming Chiao Tung University, <sup>3</sup> Lam research Corporation, Tualatin, Oregon, 97062, <sup>4</sup> Lam research Corporation, 1F,No22,R&D RD,II, Hsinchu Science Park <b>15WE2-3</b> Reliability Study of NMP-Free PI with Anti-Metal Migration Properties Daniel Chen, Wei-Chun Chen, Renata Hsiao, Fenny Liu, Allen Huang, Liang-Yih Hung, Andrew Kang, Siliconware Precision Industries Co., Ltd. <b>[15WE2-4]</b> Fine Trench Fabrication by Excimer Laser Ablation and Plasma Etching Kento Eguchi,Masatsugu Nakano,Eiichiro YamasakiShin-Etsu Engineering Co., Ltd.,	<b>15WF2: Emerging Technologies-2</b> <b>15WF2-1 &lt;Session Invited&gt;</b> AI-powered analytics for interconnect technologies utilized in electronic packaging Roland Brunner, Materials Center Leoben Forschung GmbH <b>15WF2-2</b> High-Resolution 3D Printed Microelectronics Platform for Advanced Packaging Applications Hylike Akkerman, Jeroen Sol, Darragh Walsh, Peter Rensing, Sophie Suijtdendorp, Holst Centre / TNO <b>15WF2-3</b> Investigation of Laser Parameters for the Creation of Traces and Contact Pads on Aluminum Nitride Ceramics Finn-Merlin Deckert, Cathleen Kleinholz, Christoph Heinze, Indra Kaeplinger, Thomas Ortlepp, CIS Forschungsinstitut fuer Mikrosensorik GmbH <b>15WF2-4</b> Cu Pillar Chip Bonding using 3D-Printed Fan-Out Substrate for Advanced Packaging Haksoon Jung, Jimin Kwon, Ulsan National Institute of Science and Technology (UNIST)
12:35	Lunch					
12:55	Luncheon Talk: TBD					
13:25	Break / Poster Session					
13:35	Break					
14:50	Award Ceremony					
15:00	Break					
15:30	Keynote Lecture I: TBD					
15:40	Keynote Lecture II: TBD					
16:40	Introduction to ICEP 2027					
17:40	Welcome Reception (Grand Prince Hotel Hiroshima)					
17:45						
18:15						
20:15						

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8:30 9-15	Keynote Lecture III: Advanced Thinning and Cutting Technologies Enabling AI-Oriented Heterogeneous Integration Youngsuk Kim, DISCO Corp.					
Break						
9:30	<b>16TA1: Glass PKG-1</b> <b>16TA1-1 &lt;Session Invited&gt;</b> Opportunities and Challenges of Glass Core Substrate Technologies Andreas Ostmann, Fraunhofer IZM  <b>16TA1-2 &lt;Session Invited&gt;</b> A Panel-Level Manufacturing Platform for Reliable Glass Core Substrates for Next Generation IC Packages Christian Buchner, SCHMID Group  <b>16TA1-3</b> Glasses as substrates for packaging: Remarks on Mechanic reliability connected to via-via distance and via density. Martin Letz*, Fabian Wagner*, Inge Burger*, Vanessa Glasser*, Volker Seibert*, Ulrich Peuchert*, SCHOTT AG, *SCHOTT Semicon glass solutions  <b>16TA1-4</b> From Via to Singulation - Laser Technologies Driving Glass-Based Advanced Packaging Nils Anspach, Daniel Dunker, Janis Heitz, Simon Hirt, Norbert Ambrosius, Roman Osholt, LPKF Laser and Electronics SE	<b>16TB1: ISMP-1</b> <b>16TB1-1 &lt;Session Invited&gt;</b> Bonding Strength Enhancement in Cu/SiO2 Hybrid Bonding Prof. Sungdong Kim, Department of Mechanical System Design Engineering, Seoul National University of Science and Technology  <b>16TB1-2 &lt;Session Invited&gt;</b> Understanding the interfacial reactions between dielectrics and dielectrics for hybrid bonding applications Prof. Changhwan Choi, Division of Materials Science and Engineering, Hanyang University  <b>16TB1-3 &lt;Session Invited&gt;</b> Anisotropic Conductive Adhesive for Assembly of Microchips Tae-I Kim, School of Chemical Engineering, Sungkyunkwan University  <b>16TB1-4 &lt;Session Invited&gt;</b> Signal Integrity Challenges and Opportunities in High-Density Chiplet I/O on Glass Substrates Jinin Kwon, School of Chemical Engineering, Sungkyunkwan University	<b>16TC1: Ceramic Solution</b> <b>16TC1-1</b> Feasibility study of laterally embedded ceramic inlays into Silicon substrates for sensor applications Michael Fischer, Cathleen Kleinholz, Bjørn Mueller, Alexander Schulz, Jens Mueller, Ilmenau Technical University, Electronics Technology Group  <b>16TC1-2</b> Silicon on Ceramic an Innovative Technology Platform Cathleen Kleinholz <sup>1,2</sup> , Bjørn Mueller <sup>1</sup> , Michael Fischer <sup>1</sup> , Alexander Schulz <sup>2</sup> , Andrea Cyriax <sup>1</sup> , Michael Hintz <sup>1</sup> , Thomas Ortlepp <sup>1</sup> , Jens Mueller <sup>1</sup> , Technische Universität Ilmenau, <sup>1</sup> CIS Forschungsinstitut fuer Mikrosensoren GmbH  <b>16TC1-3</b> Fabrication and Evaluation of Fully Embedded Silicon Strain Gauges in Ceramic Material for Wet Wet Applications Cathleen Kleinholz <sup>1</sup> , Thomas Frank <sup>1</sup> , Andrea Cyriax <sup>1</sup> , Stefan Jagomast <sup>1</sup> , Christian Maier <sup>1</sup> , Michael Hintz <sup>1</sup> , Annett Schroeter <sup>1</sup> , Uwe Krieger <sup>1</sup> , Thomas Ortlepp <sup>1</sup> , CIS Forschungsinstitut fuer Mikrosensoren GmbH, <sup>2</sup> VIA electronic GmbH	<b>16TD1: Cu-Cu Bonding</b> <b>16TD1-1</b> Electrodeposited Oriented Nanotwined Cu for Low Temperature Hybrid Bonding Yunwen Wu <sup>1</sup> , Xingya Pan <sup>1</sup> , Wenfeng Huang <sup>1</sup> , Yuhang Li <sup>1</sup> , Shenghong Ju <sup>1</sup> , School of Material Science and Engineering, Shanghai Jiao Tong University, <sup>2</sup> Key Laboratory for Thermal Science and Power Engineering of Ministry of Education, Department of Engineering Mechanics, Tsinghua University  <b>16TD1-2</b> A designed (110)-oriented twin structure for low temperature Cu-Cu bonding Shichen Xie, Zishan Xiong, Yingxia Liu, City University of Hong Kong  <b>16TD1-3</b> Impact of Surface Treatment Queue Time on Low-Temperature Nanocrystalline Cu Bonding Chen-Ning Li <sup>1</sup> , Artur Kolics <sup>1</sup> , Mengping Li <sup>1</sup> , Shunmita <sup>1</sup> , Graduate School of Engineering, The University of Osaka, <sup>2</sup> Joining and Welding Research Institute, The University of Osaka  <b>16TD1-4</b> In-Sn Passivated Low Temperature and Low Pressure fine-pitch Cu-Cu Interconnects Yu-Hsiang Lu <sup>1</sup> , Po-Shao Shih <sup>1</sup> , Wei Choong Lee <sup>1</sup> , Cheng-Yan Yang <sup>1</sup> , Yun-Ching Hung <sup>1</sup> , Yung-Sheng Lin <sup>1</sup> , Chen-Chao Wang <sup>1</sup> , Chih-Pin Hung <sup>1</sup> , C. Kao <sup>1</sup> , <sup>1</sup> Department of Materials Science and Engineering, National Taiwan University, <sup>2</sup> Advanced Semiconductor Engineering, Inc., Taiwan	<b>16TE1: Materials-3</b> <b>16TE1-1</b> Development of a High-Resolution, High-Reliability Photo-Imageable Dielectric Kohei Abe, Ryo Yukioka, Takeshi Nojiri, Emi Miyazawa, Takashi Kawamori, Resonac Corporation  <b>16TE1-2</b> Low-temperature Sintering Accelerating of Silver Bump-like for Improving Interconnect Characteristics by Designing Aliphatic Epoxy-based Binder Takatori Fukushima <sup>1,2</sup> , Masahiro Inoue <sup>1</sup> , Gunma University, <sup>2</sup> Research Fellow of Japan Society for the Promotion of Science  <b>16TE1-3</b> Shrinkage Behaviour and Electrical Resistivity of Pyrolyzed Carbon Lattice Yu-Yen Chen <sup>1</sup> , Hiroaki Takami <sup>1</sup> , Hiroshi Nishikawa <sup>1</sup> , Graduate School of Engineering, The University of Osaka, <sup>2</sup> Joining and Welding Research Institute, The University of Osaka  <b>16TE1-4</b> Stretchable PEDOT/PSS Films With Enhanced Electrical And Mechanical Properties For Printed Electronics Masahiro Inoue, Hideyo Shimizu, Gunma University	<b>16TF1: Thermal Management-1</b> <b>16TF1-1 &lt;Session Invited&gt;</b> High thermal conductive composite for efficient heat spreading through multi-dimensionsal strategy Bin Xu, Junichiro Shiomi, University of Tokyo  <b>16TF1-2</b> Diamond Thermal Solutions for Emerging High-Heat-Flux and High-Power Semiconductor Packaging Youshuo Tang <sup>1,2</sup> , <sup>1</sup> National Cheng Kung University, <sup>2</sup> National Tsinghua University  <b>16TF1-3</b> Ag-coated Ni Metallization for Fluxless Indium-Based TIM Bonding Yuan-Han Ku <sup>1</sup> , Cheng-Yan Yang <sup>1</sup> , Yu-Hsiang Lu <sup>1</sup> , C. Robert Kao <sup>1</sup> , <sup>1</sup> National Taiwan University, <sup>2</sup> National Taiwan University  <b>16TF1-4</b> Thermal properties of Vertically Aligned Carbon Nanotube-based Thermal Interface Materials Yoku Inoue, Tomoki Okumura, Yumoto Watanabe, Takayuki Nakano, Shizuoka University
11:10	Break					
11:25	<b>16TA2: Glass PKG-2</b> <b>16TA2-1 &lt;Session Invited&gt;</b> TBD Glass PLP HVM solution Frank Su, LAM Research  <b>16TA2-2 &lt;Session Invited&gt;</b> Reliability Evaluation of 40 µm-Pitch Solder Joint on Glass Interposer Naoko Katoh, IBM  <b>16TA2-3 &lt;Session Invited&gt;</b> Process Control Innovations for Glass in Advanced Packaging Monti Pua, Onto  <b>16TA2-4 &lt;Session Invited&gt;</b> Next Generation High Energy Efficiency Packaging Study Utsunomiya, Interconnection Tech	<b>16TB2: ISMP-2</b> <b>16TB2-1 &lt;Session Invited&gt;</b> Reliability of Fine-Pitch Redistribution Layers (RDLs) for Advanced Packaging Prof. Yung-Chang Joo, Department of Materials Science and Engineering, Seoul National University  <b>16TB2-2 &lt;Session Invited&gt;</b> Novel Electrochemical Processes for Advanced Packaging Prof. Bongyoung Yoo, Department of Materials and Chemical Engineering, Hanyang University, ERICA  <b>16TB2-3</b> Non-Invasive Visualization of Corrosion in Electronic Packages Using a Conditional Diffusion Model Trained on S-Parameters Tae Yeob Kang, The University of Suwon  <b>16TB2-4</b> Clustering-Enhanced Deep Surrogate Model for Global Stress and Weak-Point Detection in Semiconductor Packaging Boo Soo Ma <sup>1</sup> , Boyeon Kim <sup>1</sup> , Myoung Song <sup>1</sup> , Tae Yeob Kang <sup>1</sup> , Taek-Soo Kim <sup>1</sup> , University of Suwon, <sup>2</sup> Korea Advanced Institute of Science and Technology (KAIST)	<b>16TC2: Direct Bonding</b> <b>16TC2-1</b> A Process-Chemistry Map for Room-Temperature Dielectric Bonding Yun-Hsuan Chen <sup>1</sup> , Guanyu Song <sup>1</sup> , Cheng-Chieh Kao <sup>1</sup> , Chih Chen <sup>1</sup> , National Yang Ming Chiao Tung University, <sup>2</sup> Lam Research Corporation  <b>16TC2-2</b> A Comparison Study on Room Temperature Bonding of Sapphire-Sapphire and Al2O3 Film-Al2O3 Film Kenji Uno, Ryo Takigawa, Graduate School of Information Science and Electrical Engineering, Kyushu University  <b>16TC2-3</b> Study on Surface Uniformity Improvement of Ag Nanoparticle Formed by Galvanic Deposition Quan-Wei Yip, Cheng-Min Yen, Shih-kang Lin, National Cheng Kung University  <b>16TC2-4</b> Heterogeneous Integration of LiNbO3 And Si Dies Using Room-Temperature Au-Au Bonding in Ambient Air With O2 Plasma Treatment Matsunobu Kosei, Takigawa Ryo, Kyushu University	<b>16TD2: Others</b> <b>16TD2-1</b> Reliability Assessment of Hybrid Bonding Interconnects under Electromigration Stress Min-Yan Tsai, Shao-Bo Wang, Yang-Sheng Lin, Yu-Ren Chang, Che-Ming Hsu, Chih-Jing Hsu, Zhao-Ze Jiang, Chen-Chao Wang, Chih-Pin Hung, Advanced Semiconductor Engineering  <b>16TD2-2</b> Enhanced electromigration resistance by nanotwined Cu-Ag Interconnects for advanced packaging Fan-Yi Ouyang, Peng-Hsiang Hsu, National Tsing Hua University  <b>16TD2-3</b> Characterization for the Bottom Joint of Stacked Micro-via Integrated in the Substrate by ToF-SIMS and STEM Masahiko Nishiyama <sup>1</sup> , Ming-Chun Hsieh <sup>1,2</sup> , Rieko Okumura <sup>1</sup> , Hiroyoshi Yoshida <sup>1</sup> , Cuantong Chen <sup>1</sup> , Hiroki Seto <sup>1</sup> , Kei Hashizume <sup>1</sup> , kimihito yamanaka <sup>1</sup> , Hiroshi Nishikawa <sup>1</sup> , Katsusaki Sugimura <sup>1</sup> , SANKEI, The University of Osaka, <sup>2</sup> Okuno Chemical Industries Co., Ltd., JWRI, The University of Osaka  <b>16TD2-4</b> Corrosion Behavior of Cu-to-Cu Direct Bonding by Refill Friction Stir Spot Welding for Bus Bar Application HAYOUNG YU <sup>1,2</sup> , Myoung-Gyu Lee <sup>2</sup> , Dongjin Kim <sup>1</sup> , <sup>1</sup> Korea Institute of Industrial Technology (KITECH), <sup>2</sup> Seoul National University	<b>16TE2: Materials-4</b> <b>16TE2-1</b> Low-Temperature Sintering of Cu Microparticle/Cu2O Nanoparticle Composite Pastes for High-Strength Bonding Tetsu Yonezawa <sup>1</sup> , Takashi Aso <sup>1</sup> , Hokkaido University, <sup>2</sup> Chulalongkorn University  <b>16TE2-2</b> Nickel-Enhanced Copper Complex Inks With Improved Weather Resistance Zheng Yi <sup>1</sup> , Tsukamoto Hiroki <sup>1</sup> , Yonezawa Takashi <sup>1</sup> , Division of Materials Science and Engineering, Hokkaido University, <sup>2</sup> Department of Chemical Engineering, Chulalongkorn University  <b>16TE2-3</b> High-Strength Cu Joint Fabricated Using Bimodal-Sized Cu Nanoparticles Qianhao Zao, Tetsu Yonezawa, Faculty of Engineering, Hokkaido University  <b>16TE2-4</b> Surface Modification of Fine Grain Copper for Low-Temperature Hybrid Bonding Taiki Miyamoto <sup>1</sup> , Kenta Hayama <sup>1</sup> , Fabiana Tanaka <sup>1</sup> , Yutetsu Kamiya <sup>1</sup> , Marie Sano <sup>1</sup> , Ryohta Nakai <sup>1</sup> , Ryo Tanaka <sup>1</sup> , Fumihito Inoue <sup>1</sup> , Yokohama National University, <sup>2</sup> Okuno Chemical Industries Co., Ltd.	<b>16TF2: Thermal Management-2</b> <b>16TF2-1</b> Room-Temperature Wafer Direct InP/SiC Bonding Via Plasma Activated Bonding Method JUMPEI NAKAMURA, Ryo Takigawa, Kyushu University  <b>16TF2-2</b> Development of high heat dissipation insulated metal substrates using thin insulating films YUKIHIRO WATANABE <sup>1</sup> , Mitsuru Nishimura <sup>1</sup> , Yasuyuki Yanase <sup>1</sup> , Kenzo Usami <sup>1</sup> , Yutaka Takagi <sup>1</sup> , Katsuyuki Sakata <sup>1</sup> , Keiji Takagi <sup>1</sup> , Akiyoshi Hattori <sup>1</sup> , Niterra Co., Ltd., <sup>2</sup> NTK Ceramic Co., Ltd.  <b>16TF2</b>

	Room A	Room B	Room C	Room D	Room E	Room F
8:30	Keynote IV: The Future of Computing					
9:15	Norishige Morimoto, IBM Japan, Ltd.					
9:15	Keynote V: TBD					
10:00						
Break						
10:15	<b>17FA1: IMPACT</b> <b>17FA1-1 &lt;Session Invited&gt;</b> TBD Dr. Chien-Yung Ma, Forcera Materials Inc. <b>17FA1-2 &lt;Session Invited&gt;</b> TBD Prof. Yong-Hua Tzeng, NCKU. <b>17FA1-3 &lt;Session Invited&gt;</b> TBD Dr. Shin-Puu Jeng, Applied Materials <b>17FA1-4</b> Cross-interface grain growth in Cu-Cu Bonding Prof. Chih-Ming Chen, National Chung Hsing University	<b>17FB1: Printed Electronics</b> <b>17FB1-1 &lt;Session Invited&gt;</b> Printed Organic Thin-Film Transistors for Large-Area Integrated Electronics Prof. Xuying Liu, Zhengzhou University <b>17FB1-2 &lt;Session Invited&gt;</b> Low-temperature copper sinter-joining technology for next-generation Prof. Wanli Li, Jiangnan University <b>17FB1-3 &lt;Session Invited&gt;</b> Directed self-assembly for high resolution stretchable electronics Dr. Lingying Li, NIMS <b>17FB1-4</b> TBD	<b>17FC1: Hybrid Bonding-1</b> <b>17FC1-1 &lt;Session Invited&gt;</b> TBD <b>17FC1-2</b> Low Temperature Hybrid Bonding Process by Surface Modification using Low-Molecular-Weight Organic Material Chihiro Nakagawa <sup>1</sup> , Yoshikage Ohmukai <sup>1</sup> , Hosoda Kazuki <sup>1</sup> , Yuuki Araga <sup>1</sup> , Naoya Watanabe <sup>1</sup> , Haruo Shimamoto <sup>1</sup> , Kenji Takahashi <sup>1</sup> , Takashi Namikawa <sup>1</sup> , Katsuya Kikuchi <sup>1</sup> , Daikin Industries, Ltd., <sup>1</sup> National Institute of Advanced Industrial Science and Technology <b>17FC1-3</b> In-situ Analysis of SiO <sub>2</sub> Surface Chemistry Evolution During N <sub>2</sub> Annealing for Hybrid Bonding Applications Haibo Yang, Fei Ding, Yu Zhang, Yudong Yang, Qushu Kang, Hongchao Zhang, Lingyun Zhang, Yihao Meng, Renxi Jin, Qidong Wang, Institute of Microelectronics, Chinese Academy of Sciences <b>17FC1-4</b> High-Resolution 3D X-Ray Imaging of Hybrid Bonding Till Dreier, Daniel Nilsson, Shihō Tanaka, Excillum AB	<b>17FD1: Mech simulation-2</b> <b>17FD1-1</b> Physical Estimation of Epoxy Flux Pattern Design of Multi-Chip Module Packaging Kuan-Wei Choe <sup>1</sup> , Chih-Yang Weng <sup>2</sup> , You-Yi Zheng <sup>3</sup> , Shen-Yu Yang <sup>4</sup> , Chao-Chieh Chan <sup>1</sup> , Chun-Wei Wang <sup>1</sup> , Jui-Chang Chuang <sup>1</sup> , Chang-Chun Lee <sup>1</sup> , <sup>1</sup> National Tsing Hua University, <sup>2</sup> WNC Corporation <b>17FD1-2</b> Simulation of NMSD Type in CUF Parameters and Substrates on Reliability TZU CHIEH CHHEN, Yuan Hung Sun, Yu Chi Sung, Chao Lin Shih, Chi Chung Liu, Lu Ming Lai, Kuang Hsiung Chen, Advanced Semiconductor Engineering, Inc Chung-Li Branch <b>17FD1-3</b> Capillary Underfill Simulation across Die-to-Die Gap Using Hybrid EBG Modeling Leo Shen <sup>1</sup> , Kazuki Noguchi <sup>1</sup> , Yu-En Liang <sup>1</sup> , Wei-Yu Lin <sup>1</sup> , Zi-Hsuan Wei <sup>1</sup> , Ching-Kai Chou <sup>1</sup> , Ming-Yu Lin <sup>1</sup> , <sup>1</sup> CoreTech System Co., Ltd. (Moldex3D), <sup>2</sup> Sanyu rec co., Ltd. <b>17FD1-4</b> Numerical Simulation and Machine Learning-Based Optimization of Mass Reflow Temperature Profiles in Batch-Produced System-in-Packages Jan Hu, Xuan-Zhi Kuo, National Kaohsiung University of Science and Technology	<b>17FE1: High-Speed, Wireless &amp; Components</b> <b>17FE1-1</b> A Compact Dual-Band AIP Integrated Beamforming IC Using Package-on-Package Technology for Mobile Devices Sheng-Chi Hsieh, Advanced Semiconductor Engineering, Inc.(ASE group) <b>17FE1-2</b> Design of millimeter-wave antenna array in package featured with bandpass impedance transformation Simin Wang <sup>1</sup> , Kuofeng Cheng <sup>1</sup> , ShengFu Chang <sup>1</sup> , ShihCheng Lin <sup>1</sup> , ChenChao Wang <sup>1</sup> , <sup>1</sup> National Chung Cheng University, <sup>2</sup> Advanced Semiconductor Engineering <b>17FE1-3</b> Fabrication tolerance analysis of multi-layers package substrate for 5G mmWave Antenna in Package/Module (AIP/AIM) Cheng Yu Huo, Pingtung <b>17FE1-4</b> Development of Integrated Q-band 4x4 Phased-Array Module with High Aspect Ratio Cu-Pillar Pins and M7-Level SLP for High-Efficiency mmWave NTN Applications Li-Cheng Shen <sup>1</sup> , Wei-Yang Chen <sup>1</sup> , Ming-Hung Chang <sup>1</sup> , Leo Hsu <sup>1</sup> , Su-Wei Chang <sup>1</sup> , <sup>1</sup> Universal Global Scientific Industrial Co., Ltd. (USI), <sup>2</sup> TMYTEK Co., Ltd.	<b>17FF1: Thermal Management-5</b> <b>17FF1-1</b> A Thermal Isolation Method Based on "Parylene-Kirgarm" Structure for Silicon-Based 2.5D Heterogeneous Integration Systems Zhou Yang, Han Xu, Lang Chen, Huiquan Cao, Jianyu Du, Chi Zhang, Wei Wang, Peking University <b>17FF1-2</b> Co Integrated Cu/Sn Electrical and Fluidic I/Os for Embedded Microchannel Cooling in 3D ICs Using FOWLP Shaofeng Wang <sup>1</sup> , Zhou Yang <sup>1</sup> , Shangyang Shi <sup>1</sup> , Yudong Yang <sup>1</sup> , Wei Wang <sup>1,2,3</sup> , Chi Zhang <sup>1,2,3</sup> , <sup>1</sup> Peking University, <sup>2</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology, <sup>3</sup> Beijing Advanced Innovation Center for Integrated Circuits <b>17FF1-3</b> chip-level silicon vapor chamber with MEMS microchannel wick for hotspot cooling and g-rout-robust operation Jianyu Du <sup>1</sup> , Jiale Tu <sup>1</sup> , Haoyang Sun <sup>1</sup> , Shangyang Shi <sup>1</sup> , Feng Ji <sup>1</sup> , Chi Zhang <sup>1,2,3</sup> , Wei Wang <sup>1,2,3</sup> , <sup>1</sup> Peking University, <sup>2</sup> Beijing Institute of Remote Sensing Equipment, <sup>3</sup> Beijing Advanced Innovation Center for Integrated Circuits, <sup>4</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology <b>17FF1-4</b> Numerical Simulation and Analysis of Heat Transfer Characteristics of Through Silicon Vias in Backside Power Delivery Networks Shizun Hu <sup>1</sup> , Yutong Fu <sup>1</sup> , Huiquan Cao <sup>1,2,3,4</sup> , Shangyang Shi <sup>1</sup> , Chi Zhang <sup>1</sup> , Wei Wang <sup>1,2,3</sup> , <sup>1</sup> Peking University, <sup>2</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology, <sup>3</sup> Beijing Advanced Innovation Center for Integrated Circuits, <sup>4</sup> China University of Geosciences (Beijing)
11:55						
Lunch Time						
12:45	<b>17FA2: Glass-PKG3</b> <b>17FA2-1 &lt;Session Invited&gt;</b> Progress and Remaining Challenges for Glass Core Substrates Jan Vardaman, TechSearch <b>17FA2-2 &lt;Session Invited&gt;</b> Enabling Next-Generation Packaging with Glass and Quartz Core Substrates Jonas Discher, PlanOptik <b>17FA2-3 &lt;Session Invited&gt;</b> TBD Glass core evaluation method TBD Prof. Ming-Yi Tsai <sup>1</sup> , T. Onishi, CGU Chang Gung U EDU TW / GJT <b>17FA2-4</b> Development of glass core multilayer build-up substrate with TGV Jun Yoshiike, Masahiro Sunohara, Gai Kadoishi, Yuki Nakabayashi, Noriyoshi Shimizu, Ryoichi Matsuki, Shinko Electric Industries co., LTD	<b>17FB2: ICEPT</b> <b>17FB2-1 &lt;Session Invited&gt;</b> Advancements in Ultra-High Aspect Ratio Via Interconnection Technology Enabled by Atomic Layer Deposition Daquan Yu, Xiamen Sky Semiconductor Co., Ltd., China <b>17FB2-2 &lt;Session Invited&gt;</b> Thermal Management of Chip Wei Wang, Peking University, China <b>17FB2-3 &lt;Session Invited&gt;</b> The Simulation and Testing of UCLE Power Noise Based on Chiplet Chenxi Yang, Samechips Technology Co., Ltd., China <b>17FB2-4 &lt;Session Invited&gt;</b> SiC Advanced Packaging and All-Copper Solutions Huaiyu Ye, Southern University of Science and Technology	<b>17FC2: Hybrid Bonding-2</b> <b>17FC2-1</b> Development of Anti-oxidation Technology for Cu Direct Bonding via Ascorbic Acid Vapor Jeechoo Na <sup>1,2</sup> , Eunhye Lee <sup>1</sup> , Suin Jang <sup>1</sup> , Dongwoo Lee <sup>1</sup> , Tae-Ik Lee <sup>1</sup> , <sup>1</sup> Korea Institute of Industrial Technology, <sup>2</sup> Sungkyunkwan University <b>17FC2-2</b> Electrodeposition of (111)-Oriented Cu Using Accelerator for Cu-Cu Direct Bonding Soojin Kim, Hanyang university <b>17FC2-3</b> Effect of Pressure on Grain Growth in Nanocrystalline Cu for Low-Temperature Cu-Cu Bonding Ting-Chi Chen, Chih Chen, National Yang Ming Chiao Tung University <b>17FC2-4</b> The role of densification on deformation behavior of sintered Ag during nanoindentation creep test Seonghwan Park <sup>1</sup> , Hiroaki Tatsumi <sup>1</sup> , Hiroshi Nishikawa <sup>1</sup> , <sup>1</sup> The University of Osaka, <sup>2</sup> The University of Osaka <b>17FD2-4</b> Defects in Cu-filled through-silicon vias (TSV) after thermal cycling Zishan Xiong <sup>1</sup> , Shichen Xie <sup>1</sup> , Zeyuan Li <sup>1</sup> , Sheng Liu <sup>1</sup> , Yizheng Guo <sup>1</sup> , Yingxia Liu <sup>1</sup> , <sup>1</sup> City University of Hong Kong, <sup>2</sup> City University of Hong Kong, <sup>3</sup> Wuhan University	<b>17FD2: Reliability-1</b> <b>17FD2-1</b> In-situ observation of dislocation movement, accumulation and crack propagation behaviour during tensile loading in Sn and Sn-based solder alloys Kazuhiko Nogita <sup>1</sup> , Jiye Zhou <sup>1</sup> , Xin Fu Tan <sup>1</sup> , Stuart McDonald <sup>1</sup> , Keith Swathmore <sup>2</sup> , Hiroshi Maeno <sup>1</sup> , Syo Matsumura <sup>1</sup> , Kazuhiro Yasuda <sup>1</sup> , <sup>1</sup> The University of Queensland, <sup>2</sup> Nihon Superior Co., <sup>3</sup> Kyushu University <b>17FD2-2</b> Microcrack-sliding Damping During Crack Propagation in Pure Sn Under Electric Current Stressing Fei Hu <sup>1</sup> , Ming Tang <sup>1</sup> , Wangyuan Li <sup>1,3</sup> , <sup>1</sup> Gulin University of Electronic Technology, <sup>2</sup> Chongqing Sile Product Quality Testing Co., Ltd., <sup>3</sup> Southwest Jiaotong University <b>17FD2-3</b> The role of densification on deformation behavior of sintered Ag during nanoindentation creep test Seonghwan Park <sup>1</sup> , Hiroaki Tatsumi <sup>1</sup> , Hiroshi Nishikawa <sup>1</sup> , <sup>1</sup> The University of Osaka, <sup>2</sup> The University of Osaka <b>17FD2-4</b> Defects in Cu-filled through-silicon vias (TSV) after thermal cycling Zishan Xiong <sup>1</sup> , Shichen Xie <sup>1</sup> , Zeyuan Li <sup>1</sup> , Sheng Liu <sup>1</sup> , Yizheng Guo <sup>1</sup> , Yingxia Liu <sup>1</sup> , <sup>1</sup> City University of Hong Kong, <sup>2</sup> City University of Hong Kong, <sup>3</sup> Wuhan University	<b>17FE2: Material Processing</b> <b>17FE2-1</b> Comparison of Cu diffusion barrier properties of electroless-plated CoWB and Co/Ni alloy films formed on SiO <sub>2</sub> /Si shoso shingubara, tomohiro shimizu, takeshi ito, Kansai University <b>17FE2-2</b> Photon-removable Protective Molecular Nanolayers for Enhancing Cu to Cu Direct Bonding Wei-Ting Chen <sup>1</sup> , Ting-Hsiang Hsueh <sup>1</sup> , Chih-Ming Chen <sup>1</sup> , Takafumi Fukushima <sup>1</sup> , Jenn-Ming Song <sup>1</sup> , <sup>1</sup> National Chung Hsing University, <sup>2</sup> National Chung Hsing University, <sup>3</sup> National Chung Hsing University <b>17FE2-3</b> Effect of Binder Chemistry on Dynamic Percolation of Stretchable Printed Wires During Vacuum Foaming Rima Aida, Masahiro Inoue, Gunma University <b>17FE2-4</b> Advanced Hybrid Smear Removal Process with Excimer VUV Treatment for Next-Generation Organic Substrate Packaging Taro Arimoto <sup>1</sup> , Yukihisa Baba <sup>1</sup> , Yuhei Kitahara <sup>1</sup> , Tomoya Sawada <sup>1</sup> , Takashi Katou <sup>1</sup> , Masasumi Kusunoki <sup>1</sup> , Tatsuya Koga <sup>1</sup> , USHIO Inc., <sup>1</sup> Okuno chemical industries co. ltd, <sup>2</sup> Shikoku chemicals corporation	<b>17FF2: Power Electronics-1</b> <b>17FF2-1</b> Development of Low-Temperature Air-Sinterable Copper Paste for Die Attach and Substrate-to-Heatsink Bonding Chuantong Chen <sup>1</sup> , Fupeng Huo <sup>1</sup> , Sangmin Lee <sup>1</sup> , Takeshita Kazutaka <sup>1</sup> , Yoshiyuki Yamaguchi <sup>1</sup> , Yashima Momose <sup>1</sup> , Katsuki Suganuma <sup>1</sup> , <sup>1</sup> The university of Osaka, <sup>2</sup> Yamato Scientific Co. Ltd. <b>17FF2-2</b> Room Temperature Chip Bonding of SiC And Cu Using Activated Cu Atomic Layer Ryoshe Nanauchi, Jun Usami, Ryo Takigawa, Kyushu University <b>17FF2-3</b> X-ray Observation Microscopy for Non-destructive Observation of Grain Boundaries in Die-attach Solder Yujiro Hayashi <sup>1</sup> , J. Kim <sup>1</sup> , M. Yabashi <sup>1</sup> , H. Tatsumi <sup>1</sup> , <sup>1</sup> Riken Spring-8 Center, <sup>2</sup> Osaka University
14:25						
Break						
14:40	<b>17FA3: Glass PKG-4</b> <b>17FA3-1</b> Physical Estimation for Residual Stress of Glass Substrate through Photoelasticity-FEA Hybrid Model Jui-Chang Chuang <sup>1</sup> , Chang-Chun Lee <sup>1</sup> , Wan Chen Yang <sup>1</sup> , Po-Yu Chen <sup>1</sup> , Hao-Zhou Lin <sup>1</sup> , Wei-Cheng Tsai <sup>1</sup> , Chen-Tsai Yang <sup>1</sup> , Man-Ning Lin <sup>1</sup> , Po-Chi Sung <sup>1</sup> , Wei-Chung Wang <sup>1</sup> , <sup>1</sup> Industrial Technology Research Institute, <sup>2</sup> National Tsing Hua University <b>17FA3-2</b> Micro-crack-free Laser Singulation and melting TGV for Glass Substrate Eunsuk Jeon, Jinpyo Kim, Duhyun Cho, Lasercraps Co. Ltd. <b>17FA3-3</b> Analysis of Delamination Mechanism During the Dicing Process of Glass Substrates Chuan Chen, Institute of Microelectronics, Chinese Academy of Sciences	<b>17FB3: Co-packaged OPT</b> <b>17FB3-1 &lt;Session Invited&gt;</b> Optical Chiplet Using Membrane III-V Photonic Devices Suruu Yamaoka, NTT Device Innovation Center <b>17FB3-2 &lt;Session Invited&gt;</b> High-integration thin-film lithium niobate modulator based on heterogeneous integration technology Shuntaro Makino, FITEEL Optical Components <b>17FB3-3 &lt;Session Invited&gt;</b> Fusion of Electric and Photonic Interconnects: An Advanced Packaging Perspective Vincent Lin, ASE Group <b>17FB3-4 &lt;Session Invited&gt;</b> Multi-Die Optical Chiplet Packaging for AI Scale-Up and Scale-Out Surya Bhattacharya, Agency for Science, Technology and Research (A*STAR), Institute of Microelectronics (IME)	<b>17FC3: Hybrid Bonding-3</b> <b>17FC3-1</b> Establishment of High-Yield and Reliable Cu-Cu Connections with 0.8 Micrometers Pitch Integration Hitomi Shiina, Yukako Ikegami, Ken Arano, Kan Shimizu, Yoshinshi Kagawa, Sony Semiconductor Solutions Corporation <b>17FC3-2</b> Copper oxide in TCB Cu-Cu bonding Kuan-Yun Zeng, Shih-Kang Lin, National Cheng Kung University <b>17FC3-3</b> Surface Reduction and Self-Passivation in a Single-Step Ar/CH <sub>4</sub> Plasma treatment for Hybrid Cu Bonding Hoogwan Lee, Byoungchan Go, Sarah Kim, Seoul National University of Science and Technology <b>17FC3-4</b> Optimized Surface Treatment Strategies for Improved Cu-Cu Direct Bonding Kings Kondracka <sup>1</sup> , Cyrille Sebert <sup>1</sup> , Patrick Verdonck <sup>1</sup> , Kristof Wouters <sup>1</sup> , Nadezda Kuznetsova <sup>1</sup> , Patrick Mercken <sup>1</sup> , Michael Krafft <sup>1</sup> , KU Leuven, <sup>1</sup> KU Leuven, imec <sup>2</sup> , Xenics	<b>17FD3: Reliability-2</b> <b>17FD3-1</b> Lifetime Prediction of Die Cracking in Heatsink-Clamped FCGFN Packages under Thermomechanical Loading Shumpei Murakami, Yuki Yoshihara, Daiki Kobayashi, Ryuki Kusakabe, Marie Sano, Fumihito Inoue, Yokohama National University <b>17FD3-2</b> Thermal and Drop Reliability Performance of Low Temperature Solder in Fan-Out WLCSF Structure Nien Chun Lin, Sheng Hong Zhang, Yan Bo Lin, Chih Sheng Su, Hsin Chih Shih, Chin Li Kao, Chen Chao Wang, C.P. Hung, Advanced Semiconductor Engineering, Inc. <b>17FD3-3</b> Experimental and numerical analysis of a fan-out BGA Chip on PCB reliabilities under drop test loads jian cheng, JCET Group <b>17FD3-4</b> Deep Learning Based Reliability Prediction for BL-TGT Lifetime of Aiskoid FCBGA Packages Yang-Yuan Chen, Chen-Chao Wang, Chin-Pin Hung, Advanced Semiconductor Engineering, Inc.	<b>17FE3: Measurement Method</b> <b>17FE3-1</b> Integrating Mechanical and Chemical Insights Into Bonding Interfaces via DGB-Based Delamination Analysis Shumpei Murakami, Yuki Yoshihara, Daiki Kobayashi, Ryuki Kusakabe, Marie Sano, Fumihito Inoue, Yokohama National University <b>17FE3-2</b> Quantitative Assessment of Bond Strength for Hybrid Bonding Ryuki Kusakabe <sup>1</sup> , Daiki Kobayashi <sup>1</sup> , Yuki Yoshihara <sup>1</sup> , Shumpei Murakami <sup>1</sup> , Sano Marie <sup>1</sup> , Shunsuke Teranishi <sup>1</sup> , Yuya Matsuka <sup>1</sup> , Daichi Saito <sup>1</sup> , Naoko Yamamoto <sup>1</sup> , Fumihito Inoue <sup>1</sup> , <sup>1</sup> Yokohama National University, <sup>2</sup> DISCO Corporation <b>17FE3-3</b> Performance Comparison of Machine Learning Algorithms for Real-Time Temperature Measurement Using Optical-Interference Contactless Thermometry (OICT) Jiawen Yu, Hiroaki Hanafusa, Seiichiro Higashi, Hiroshima University <b>17FE3-4</b> Acoustic Emission Signal Filtering for Ultrasonic Vibration-Assisted Grinding Wheel Monitoring Using a Hydrophone Sensor YuKun Lin, Feng Chia University	<b>17FF3: Power Electronics-2</b> <b>17FF3-1</b> Near-chip 3D functionalization of direct copper bonded substrates in power electronic modules Christoph Hehl <sup>1</sup> , Dominik Wiegand <sup>1</sup> , Marcel Joerg Frankel <sup>1</sup> , Manuela Ockel <sup>1</sup> , Friedrich-Alexander University Erlangen-Nuremberg, <sup>2</sup> Siemens AG <b>17FF3-2</b> Heatsink Design and Wire Bonding Failure Analysis of an Automotive 1.2 kV SiC MOSFET Power Module in Power Cycling Tests Po-Kai Chiu, Ji-Yuan Syu, Ting-Yu Wang, Yu-Hua Wu, Kuo-Shu Kao, Tao-Chih Chang, Industrial Technology Research Institute <b>17FF3-3</b> Reliability and Thermal Resistance Characterization of Flip-Chip Interconnections in Gallium Nitride Devices Using Silver Sintering Materials Ching Kuan Lee, Ting-Yu Ke, Yan-Cheng Liu, Po-Kai Chiu, Yu-Min Lin, Industrial Technology Research Institute <b>17FF3-4</b> Junction Temperature Estimation Error of Chip-Embedded Temperature Sensor During Transient Thermal Measurement Shuichi Fukunaga, Toshiyoshi Fukami, The University of Osaka
16:20						
Break						
16:35		<b>17FC4: TSV</b> <b>17FC4-1</b> Mixed-Foundry Heterogeneous Integration of Bumpless WOW and COW Processes for System-on-Wafer Norio Chiba <sup>1</sup> , Shinji Sugatani <sup>1</sup> , Tadashi Fukuda <sup>1</sup> , Takayuki Ohba <sup>1</sup> , <sup>1</sup> Institute of Science Tokyo, <sup>2</sup> Tech Extension Co., Ltd. <b>17FC4-2</b> Efficient Image Feature Extraction Via YOLO Framework for Critical Parameter Extraction from TSV SEM Imagery SHUYAN HE <sup>1</sup> , Lang Chen <sup>2,3</sup> , Yufeng Jin <sup>1</sup> , Wei Wang <sup>2,3</sup> , <sup>1</sup> Peking University, <sup>2</sup> Peking University, <sup>3</sup> Peking University <b>17FC4-3</b> Develop Three-Dimensional Infinite Element Method of Thermal Stress for Through-Silicon Via Analysis DE-SHIN LIU <sup>1,2</sup> , WEN-HSUAN CHANG <sup>3</sup> , TING-SHENG CHANG <sup>3</sup> , ZHEN-WEI ZHUANG <sup>3</sup> , YUNG-CHING CHAO <sup>3</sup> , PEI-CHEN HUANG <sup>3</sup> , <sup>1</sup> National Chung Cheng University, <sup>2</sup> National Chung Cheng University, <sup>3</sup> National Chiayi University	<b>17FD4: Reliability-3</b> <b>17FD4-1</b> Enhancement of Micro-DIC Technique and Deformation Measurement of Fine-Pitch Semiconductor Packages Hyeonwoo Nam <sup>1</sup> , Seongkyu Choi <sup>1</sup> , Minjong Sohn <sup>1</sup> , Tae Yeob Kang <sup>1</sup> , Tae-ik Lee <sup>1</sup> , <sup>1</sup> Korea Institute of Industrial Technology, <sup>2</sup> University of Suwon <b>17FD4-2</b> Static Structural and Thermal Analysis of Heterogeneous 3D IC Integration With Different Interposer Materials Deyuan Jiang, Sai Reddy, National Taipei University of Science and Technology <b>17FD4-3</b> A Multiscale Simulation Study on Interfacial Crack of Dielectric in Hybrid Bonding Structure Xuanyu Ding <sup>1</sup> , Yudong Yang <sup>1,2</sup> , Chi Zhang <sup>1</sup> , Hongchao Zhang <sup>1</sup> , Fei Ding <sup>1</sup> , Yu Zhang <sup>1</sup> , Renxi Jin <sup>1</sup> , Haibo Yang <sup>1</sup> , Qushu Kang <sup>1</sup> , Lingyun Zhang <sup>1</sup> , Qidong Wang <sup>1</sup> , Wei Wang <sup>1,2</sup> , Liqiang Cao <sup>1</sup> , <sup>1</sup> School of Integrated Circuits, Peking University, <sup>2</sup> Institute of Microelectronics of the Chinese Academy of Sciences, <sup>3</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology, <sup>4</sup> Beijing Advanced Innovation Center for Integrated Circuits <b>17FD4-5</b> Pre-heating influence on thermo-mechanical response of Ag-Au-Pd alloy fine wire during wire bonding process Pei-Chen Huang <sup>1</sup> , Zhi-Lin Xie <sup>1</sup> , Wei-Lun Kao <sup>1</sup> , <sup>1</sup> National Chung Cheng University, <sup>2</sup> National Chung Cheng University	<b>17FE4: Optoelectronics</b> <b>17FE4-1</b> Reliability Evaluation of Copper Pin Package-on-Package Structures for Co-Packaged Optics Motokazu Fukuhara, Tatsuki Denza, Masaki Matsumoto, Futoshi Tsukada, Noritaka Katagiri, Shinko Electric Industries Co., Ltd. <b>17FE4-2</b> In-situ XPS Analysis of Hydroxyl Group Generation in Plasma Activation Technology Cheng Peng <sup>1,2</sup> , Yihao Meng <sup>1,2</sup> , Wenxuan Ma <sup>1,2</sup> , Yitong Zhang <sup>1,2</sup> , Siwei Sun <sup>1,2</sup> , Renxi Jin <sup>1,2</sup> , Qidong Wang <sup>1,2</sup> , Liqiang Cao <sup>1,2</sup> , <sup>1</sup> State Key Laboratory of Fabrication Technology of Integrated Circuits, <sup>2</sup> Institute of Microelectronics of Chinese Academy of Sciences, <sup>3</sup> School of Integrated Circuits, the University of Chinese Academy of Sciences <b>17FE4-3</b> Thermal Analysis and Demonstration of Mirror-based Optical Redistribution Layer for Co-packaged Optics Fumi Nakamura, Tatsuchi Suda, Takayuki Kurosu, Akhiro Noriki, Takero Amano, National Institute of Advanced Industrial Science and Technology(AIST) <b>17FE4-4</b> High-precision Passive Alignment for Multi-channel Optical Connections in Silicon Photonic Microtransceivers Michiyo Kubo, Shigeru Kobayashi, Koichi Takemura, Kazuhiko Kurata, AIO Core Co., Ltd.	<b>17FF4: Power Electronics-3</b> <b>17FF4-1</b> A Flip Chip Embedded PCB Power Module with Double Sided Cooling and Low Parasitic Inductance for Fine Pad Power Devices KAO CHE, Lin Han, Huang Cheng, Chi Kai, Lin Ying, Lin Lung, Yeh Chan, Lin Huiung, Ko Kuei, Industrial Technology Research Institute / Electronic and Optoelectronic System Research Laboratories <b>17FF4-2</b> Dynamic and Thermal Performance Evaluation of Three-Phase Full-Bridge Power Factor Correction Converters for On-Board Charger Applications Wen You Jhu <sup>1</sup> , Hsien-Chieh Cheng <sup>1</sup> , Yan Cheng Liu <sup>1</sup> , Tao Chih Chang <sup>1</sup> , Feng Chia University, <sup>2</sup> Feng Chia University, <sup>3</sup> Industrial Technology Research Institute <b>17FF4-3</b> Atmospheric Pressure Plasma Processes for Metal Oxide Reduction and Adhesion Improvement in Power Electronics Hisanori Miyoshi <sup>1</sup> , Dhia Salemi <sup>1</sup> , Noe Coenen <sup>1</sup> , Yasser Hamed <sup>1</sup> , Magnus Buske <sup>1</sup> , Daphne Pappas <sup>1</sup> , <sup>1</sup> Nihon Plasmatreut Inc., <sup>2</sup> Plasmatreut GmbH, <sup>3</sup> Plasmatreut USA <b>17FF4-4</b> A Power Semiconductor Chip Rework Technology Without Thermal and Mechanical Processes Junba Baik <sup>1</sup> , Byoungchan Kim <sup>1</sup> , Ha-Young Yu <sup>1</sup> , Myoung-Gyu Lee <sup>1</sup> , Dongjin Kim <sup>1</sup> , <sup>1</sup> Korea Institute of Industrial Technology (KITECH), <sup>2</sup> Seoul National University (SNU)	
18:15						



■ Poster Session

Poster sessions will be held from 13:35-14:50 on April 15 and from 17:30-18:45 on April 16.

P01	Development of Equivalent Material Properties of Substrate/Interposer-type Components for Advanced Packaging Ya-Chi Chen, Kuo-Ning Chiang, National Tsing Hua University
P02	Utilizing Sobol Sampling and Out-of-Fold Hotspot Analysis With a Small Dataset for ANN-Based WLP Solder Joint Reliability Prediction Chang-Hsu Lo <sup>1</sup> , Kuo-Ning Chiang <sup>1,2</sup> , <sup>1</sup> National Tsing Hua University, <sup>2</sup> College of Semiconductor Research, National Tsing Hua University
P03	Towards an intelligent assistance system for prescriptive maintenance applications based on multi-agent systems in SMT-Manufacturing Felix Mahr, Cathleen Kratzke, Joerg Franke, Manuela Ockel, Friedrich-Alexander-Universitaet Erlangen-Nuernberg (FAU), Institute for Factory Automation and Production Systems (FAPS)
P04	Intelligent Troubleshooting System for SMT Assembly Lines Using GraphRAG and Knowledge Graphs Felix Mahr, Joerg Franke, Manuela Ockel, Friedrich-Alexander-Universitaet Erlangen-Nuernberg (FAU), Institute for Factory Automation and Production Systems (FAPS), Germany
P05	Experimental Study on the Forced Convection Effectiveness of a Double-Tube Thermal Module for Electronic Packaging Chi-Ming Lai, C.J. Ho, R.H. Chen, S.H. Huang, National Cheng Kung University
P06	Microstructural and Thermo-mechanical Behavior of CuAl Bilayer Alloy for Low-Temperature Hybrid Bonding Sarabjot Singh, Kathleen Dunn, University at Albany, State University of New York
P07	Latent Catalysts Development for Energy Saving Semiconductor Packaging Application Yi Chen, Chih Lin, Kai Chen, Industrial Technology Research Institute
P08	Prediction and Analysis of Bifurcation Warpage in Wafer Packaging based on Machine Learning Chi-Hsiang Su, Kuo-Shen Chen, Chen-Chen Lee, Ching-Jeng Ho, National Cheng-Kung University
P09	Feasibility and Reliability Considerations of Liquid Metal Alloys in Advanced Packaging. Wen-Yu Teng, Siliconware Precision Industries Co., Ltd.
P10	Coupling Model Analysis Between E-field Probe and DUT in Non-Contact Near-Field Measurement YU-CHIEH CHEN, Sung-Mao Wu, National University of Kaohsiung
P11	Synthesis and characterization of thermally conductive carbon nanotube-reinforced polysiloxane composites Chih-Feng Wang <sup>1</sup> , Pei-Rung Hung <sup>2</sup> , Pei-Kang Huang <sup>3</sup> , Ping-Feng Yang <sup>1</sup> , <sup>1</sup> National Sun Yat-sen University, <sup>2</sup> Shou University, <sup>3</sup> Advanced Semiconductor Engineering, Inc.
P12	Development of A 650V / 300GaN Half-bridge Power Module Yuto Kinoshita <sup>1</sup> , Kotaro Okano <sup>1</sup> , Shota Yamada <sup>1</sup> , Tatsumi Yamamoto <sup>1</sup> , Takeya Matsumoto <sup>1,2,4</sup> , Eigo Fukuda <sup>4</sup> , Takaharu Takeshita <sup>1,2,4</sup> , Toshihiko Noguchi <sup>1</sup> , Masato Omori <sup>1,2,4</sup> , <sup>1</sup> Oita University, <sup>2</sup> Nagoya Institute of Technology, <sup>3</sup> Shizuoka University, <sup>4</sup> Next Semiconductor, Inc.
P13	Surface smoothing based on Au film transfer for room-temperature GaN/diamond bonding in air Shintaro Goto, Shogo Koseki, Kai Takeuchi, Eiji Higurashi, Tohoku University
P14	Thru Kits realized by Substrate-Integrated Waveguide architecture for Double-side calibration Wu Ji-Hsuan, Wu Sung-Mao, National University of Kaohsiung
P15	Nanoindentation Investigation of Through Substrate Vias Drilled by Ultrashort Pulse Laser Percussion RUENN TSAI, Sheng-Wei Tsai, Jih-li-Syuan Jian, National Sun Yat-sen University
P16	Broadband Transition from Microstrip to Inverted Microstrip Gap Waveguide Using Via-Guards Copper Via RUENN TSAI <sup>1</sup> , Po-Kai Hsu <sup>1</sup> , Wei-Long Chen <sup>1</sup> , <sup>1</sup> National Sun Yat-sen University, <sup>2</sup> ASE Group Taiwan
P17	Construction of Chitosan/Poly(vinyl alcohol)/Poly(ethylene oxide) Scaffolds Via Electrospinning Technology YOUJIE TSAI, JHENGHEN TU, ZHEYIYI WU, I-SHOU University
P18	Perovskite La0.8Sr0.2Mn1-xNi0.3Nanofibers Of Electrospinning Kai Chen, I-SHOU University
P19	Analysis of Au and Ru Passivation Layers Deposited via Electroless Plating for Low-Temperature Cu-Cu Bonding Byeongchan Go, hoogwan lee, sarah eunkyoung kim, Seoul National University of Science and Technology
P20	Machine Learning-Based Surrogate Model of Thermal Simulation for Heat Sink Design Seongju Kim <sup>1</sup> , Jinin Kwon <sup>1</sup> , <sup>1</sup> Hanbat National University, <sup>2</sup> UNIST
P21	New Concept of Intrinsically Switched Tunable Bandpass Filter Using Multi-band Resonators Akchito Shiotake, Hiroki Matsuura, Junichiro Matsuki, Koji Wada, The University of Electro-Communications
P22	Fan-out RDL technology development for shuttle service Chen Chun Yu, Industrial Technology Research Institute
P23	Development of AIN Fillers for Composite Resins with High Thermal Conductivity and Low Bond-Line Thickness Yusaku Imasaka, Atsushi Sanagawa, Isao Masada, Go Hamasaka, Yukihiko Kanechika, Tokuyama Corporation
P24	Investigation of Electrical and Reliability Properties in Nanowinned Sintered Joints Shin-Yi Huang <sup>1</sup> , Po-Kai Chiu <sup>1</sup> , Yung-Min Hsieh <sup>1</sup> , Yu-Hua Wu <sup>1</sup> , Fan-Yi Ouyang <sup>1</sup> , <sup>1</sup> Industrial Technology Research Institute, <sup>2</sup> National Tsing Hua University
P25	Thermal Stress and Interfacial Reliability Analysis of HAR Sub-10um Through-Glass Via (TGV) Structures for High-Frequency Applications Wei-Ting Chiu <sup>1</sup> , Yeong-Jyh Lin <sup>1</sup> , Chun-Ming (Albert) Wang <sup>1</sup> , <sup>1</sup> Wei-Ting Chiu, <sup>2</sup> Yeong-Jyh Lin, <sup>3</sup> Chun-Ming (Albert) Wang
P26	Warpage of Organic RDL Interposers in 3D Heterogeneous WLP via a Chip-First Hybrid Bonding Process Ching-Feng Yu <sup>1</sup> , Chao-Kai Hsu <sup>1</sup> , Chih-Cheng Hsiao <sup>1</sup> , <sup>1</sup> National United University, <sup>2</sup> Industrial Technology Research Institute (ITRI)
P27	Performance analysis of Au and Ag metallization for silicon-adapeted LTCC horn antenna structures Cathleen Kleinholz <sup>1</sup> , Bjorn Mueller <sup>1</sup> , Alexander Schulz <sup>1</sup> , Michael Fischer <sup>1</sup> , Nesrine Jazini <sup>1</sup> , Christian Tschoban <sup>1</sup> , Karl-Friedrich Becker <sup>1</sup> , Martin Schneider-Ramelow <sup>1</sup> , Jens Mueller <sup>1</sup> , <sup>1</sup> Ilmenau Technical University, <sup>2</sup> Fraunhofer Institute for Reliability and Microintegration
P28	Low-Temperature Curable Photo-Definable Polyimide and Its Application as a Sealing Material for RF-MEMS Susumu Tanaka, Tomoki Sakai, Yumiko Okuda, Hitoshi Araki, Toray Industries, Inc.
P29	VUV-Induced Surface Activation for Cu/SiO2Hybrid Bonding -Effect of H2Concentration in H2/H2O Mixed Atmosphere- Kengo Nishio, Kejun Wu, Akihiro Shimizu, Shinichi Endo, Akihiro Shimamoto, USHIO INC
P30	Development of Sintering Silver Paste Enabling Short Time Sintering in Non-Pressure Silver Bonding Daisuke Tomotoshi, Takamichi Mori, OSAKA SODA CO., LTD.
P31	Extraction and Verification of Material Electrical Parameters with Frequency and Temperature Variation Che-Yu Huang, National Kaohsiung University
P32	FABRICATION of CU NANOCRYSTALLINE by PR ELECTROPLATING METHOD and INFLUENCE of ADDITIVES on GRAIN SIZE Masato Tsuchiya, Yuma Sato, Katsuji Nakamura, Senju Metal Industry Co., Ltd.
P33	Development of Electromagnetic Shielding Material Testing Technology Yen Ting Lu, National University of Kaohsiung(Micro Electronic Packaging Laboratory)
P34	Cu Electrodeposition with a Single Additive for Bottom-Up Filling of TSVs Seolim Yoon, Hui Won Eom, Haejin Kwak, Yun Ha, Myung Jun Kim, Sungkyunkwan University
P35	Defect-Free TGV Filling via Cu Electrodeposition with Ammonium-based Additives Hui Won Eom, Seonjin Yang, Haejin Kwak, Dong Kun Cha, Myung Jun Kim, Sungkyunkwan University
P36	Innovative Tools and Materials for Advanced Packaging Developed in Taiwan Chien-Yung Ma, Openness Specialty Materials Corp
P37	Comparative Evaluation of Sputtered Transition-Metal Thin Films on ITO for Hydrogen Evolution Reaction Tsu Chen <sup>1</sup> , Hsu Lin <sup>1</sup> , Jun Mizuno <sup>1</sup> , <sup>1</sup> National Cheng Kung University, <sup>2</sup> Kun Shan University
P38	Microstructure Modeling, Prediction, and Verification of Cu-Ag Sintered Paste for Die-attach Based on the Quartet Structure Generation Set (QSGS) Algorithm Xinyue Wang <sup>1</sup> , Wenting Liu <sup>1</sup> , Letao Bian <sup>1</sup> , Zhoudong Yang <sup>1</sup> , Guoqi Zhang <sup>2,3</sup> , Jing Zhang <sup>2</sup> , Pan Liu <sup>1,4</sup> , <sup>1</sup> Fudan University, <sup>2</sup> Delft University of Technology, <sup>3</sup> Heraeus Materials Technology Shanghai Ltd, <sup>4</sup> Research Institute of Fudan University in Ningbo
P39	Interfacial Corrosion Behavior Analysis of Sintered Silver and Sintered Copper Joints for Power Electronics Packaging Letao Bian <sup>1</sup> , Xinyue Wang <sup>1</sup> , Guoqi Zhang <sup>2,3</sup> , Jing Zhang <sup>2</sup> , Jianhao Wang <sup>1</sup> , Pan Liu <sup>1,4</sup> , <sup>1</sup> College of Intelligent Robotics and Advanced Manufacturing, Fudan University, <sup>2</sup> Delft University of Technology, <sup>3</sup> Heraeus Materials Technology Shanghai Ltd., <sup>4</sup> Research Institute of Fudan University in Ningbo, Zhejiang Province
P40	Sub-Micro Wiring Method for Embedded Silicon Fan-Out on Reconstructed Wafer Surface Yifan Ma <sup>1</sup> , Jianyu Du <sup>1</sup> , Wei Wang <sup>1,2,3</sup> , Chi Zhang <sup>1,2,3</sup> , Pan Zhang <sup>1,2,3</sup> , Lang Chen <sup>1</sup> , <sup>1</sup> Peking University, <sup>2</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology, <sup>3</sup> Beijing Advanced Innovation Center for Integrated Circuits
P41	GAN-Based Component Placement Generation for Automatic PCB Layout Using Historical Design Data Hiroki Yonekura, Tomio Echigo, Osaka Electro-Communication University Echigo Laboratory

P42	Mechanical Characterization of Sintered Ag Paste Via Nanoindentation for Advanced Packaging in Power Electronics Qihang Zong, Huaiyu Ye, Chenshan Gao, Southern University of Science and Technology
P43	Wafer Bonding Void Investigation with SiN Dielectric Film Yeong-Jyh Lin, National Sun Yat-sen University
P44	System-Level Fast Optimization Method for High-Speed Circuits Based on Electro-Thermal Equivalent Modeling Cheng-Hsuan Liu <sup>1,2</sup> , Sung-Mao Wu <sup>1,2</sup> , <sup>1</sup> Micro Electronic Packaging Laboratory, <sup>2</sup> National University of Kaohsiung
P45	Yield-Limiting Mechanisms Governed by Dicing and Bonding Conditions in Organic Hybrid Bonding Zhao-Ze Jiang, Alexis Garcia, Chih-Jing Hsu, Chen-Hung Lee, Po-Hsiang Wang, Wang-Chia Ching, Chen-Chung Hung, Advanced Semiconductor Engineering (ASE) Group
P46	High Throughput Silver-based Metal-organic Decomposition with Spray Coating for Package-level EMI Shielding Ming-Hung Chen, W.-H. Wang, C.-L. Huang, J.-C. Kao, Y.-E. Yeh, Advanced Semiconductor Engineering Inc.
P47	Two Phase Cooling with Microporous Wick and 3D-printed Microchannel Manifold Shangyang Shi <sup>1</sup> , Shangjin Ning <sup>1</sup> , Shaofeng Wang <sup>1</sup> , Jianyu Du <sup>1</sup> , Wei Wang <sup>1,2,4</sup> , Chi Zhang <sup>1,2,4</sup> , <sup>1</sup> Peking University, <sup>2</sup> Peking University, <sup>3</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology, <sup>4</sup> Beijing Advanced Innovation Center for Integrated Circuits
P48	Design Method for On-Chip Thermal Metamaterial Interposer Compatible with MEMS Processes via 3D-to-2D Topology Optimization Huiquan Cao <sup>1,2</sup> , Han Xu <sup>1</sup> , Zhou Yang <sup>1</sup> , Haoyang Sun <sup>1</sup> , Feng Ji <sup>1</sup> , Jiajie Kang <sup>1</sup> , Chi Zhang <sup>1,4</sup> , Wei Wang <sup>1,4</sup> , <sup>1</sup> Peking University, <sup>2</sup> China University of Geosciences (Beijing), <sup>3</sup> Beijing Institute of Remote Sensing Equipment, <sup>4</sup> National Key Laboratory of Advanced Micro and Nano Manufacture Technology
P49	A Multi-Mold Temperature-Pressure-Flow Monitoring Device Based on a Venturi Differential Pressure Sensor Rong Zhang <sup>1</sup> , Pan Zhang <sup>1</sup> , Hongxu Wu <sup>1</sup> , Shengyong Xu <sup>1</sup> , Bei Peng <sup>1</sup> , Yuxuan Yan <sup>1</sup> , Wei Wang <sup>1</sup> , <sup>1</sup> Peking University, <sup>2</sup> Wuhan Second Ship Design Institute, <sup>3</sup> Anhui University
P50	Transformer-based TSV Process Performance Yield Prediction Model Chong Chen, Yihui Cheng, Bo Wen, Yikang Ding, Lang Chen, Pan Zhang, Wei Wang, Peking University
P51	Room Temperature Direct Bonding of Lithium Niobate Wafers With Different Orientations Yoshiki Katoda, Jumpei Nakamura, Ryo Takigawa, Kyushu University
P52	High-efficiency cleaning for particle removal applied in the CoW hybrid bonding process Crystal Hsu, ASE Group
P53	Effect of Pre-Annealing Time of Ti/Ag Metallized Cu Substrate on Ag-Ag Direct Bonding for SiC Die Attach Minseo Kim <sup>1,2</sup> , Sangmin Lee <sup>1</sup> , Chantong Chen <sup>1</sup> , Seungmin Cho <sup>1,2</sup> , Myung Sik Choi <sup>1</sup> , Soongkeun Hyun <sup>1</sup> , Katsuki Suganuma <sup>1</sup> , <sup>1</sup> Inha University, <sup>2</sup> The University of Osaka, <sup>3</sup> Kyungpook National University
P54	Development of LCP membrane-based Low Dielectric Laminate for High-Frequency High-Speed Communications Seong-Dae Park, Yejun Ban, Bo-Young Kim, Myong-Jae Yoo, Hyunseung Yang, Korea Electronics Technology Institute
P55	Reliability Analysis of Copper Paste Joints between Ni/Au-Coated SiC Chips and AMB Substrates during High-Temperature Aging Seungmin Cho <sup>1,2</sup> , Chantong Chen <sup>1</sup> , Sangmin Lee <sup>1</sup> , Fupeng Huo <sup>1</sup> , Minseo Kim <sup>1,2</sup> , Katsuki Suganuma <sup>1</sup> , <sup>1</sup> Inha Manufacturing Innovation School, <sup>2</sup> The University of Osaka
P56	Influence of Copper Oxidation on the Characteristics of mmWave Microstrip Antennas Yu Hsun Chang, Chih-Ling Chang, Ying-Chih Chiang, Cheng-En Ho, Yuan Ze University
P57	ANN Surrogate Model for Signal Integrity Prediction of FCGBA Soojin Lim, Soyoung Kim, Sungkyunkwan University
P58	GNN-Based Early Power Integrity Estimation for PDN Design Seonghyun Park, SoYoung Kim, Sungkyunkwan University
P59	Surrogate Model for Junction Temperature Prediction for High-Performance Computing Chips Using Direct-to-Chip Liquid Cooling technology Jiaxin Wang, Xiong Xiao, Jiapeng Huang, Zhizhen Wang, Shenglin Ma, Xiamen University
P60	Study on the High-Frequency Electrical Performance Degradation mechanism of RF TGV Transmission Structures During Temperature Cycling Tests Under High-Power and High-Temperature Conditions zhilin wei <sup>1</sup> , Luming Chen <sup>1</sup> , Chunlei Li <sup>1</sup> , Hai Yuan <sup>1</sup> , Shuwei He <sup>1</sup> , Shenglin Ma <sup>1</sup> , <sup>1</sup> Xiamen University, <sup>2</sup> Xian Microelectronic Technology, <sup>3</sup> China Electronics Technology Group Corporation 29th Research Institute Chengdu
P61	Interfacial Chemistry-Driven Reliability Enhancement in Air-Cured Bimodal Cu-Filled Conductive Pastes Ayumi Uchida, Masahiro Inoue, Gunma University
P62	Tailoring Electrical Properties of Printed Stretchable Wires via Binder Molecular Design for Electrically Conductive Pastes Togo Hatori, Masahiro Inoue, Haruya Okamura, Gunma University
P63	Effect of Structural Factors in Enhancing Dynamic Percolation of Multi-walled Carbon-nanotube-filled Conductive Pastes Tomoya Hanada, Gunma University
P64	Design Study of Next-Generation Hybrid Bonding Processes Hideki Kitada, Koharu Yuzawa, Takayuki Ohba, Institute of Science Tokyo
P65	PHYSICS-INFORMED SMALL-SAMPLE NEURAL NETWORK FOR SUBMICRO ETCH PROFILES PREDICTING IN SF6/O2/SiF4REACTIVE ION ETCHING Yikang Ding <sup>1</sup> , Bo Wen <sup>1</sup> , Lang Chen <sup>1</sup> , Yihui Cheng <sup>1</sup> , Chong Chen <sup>1</sup> , Yufeng Jin <sup>1</sup> , Chi Zhang <sup>1</sup> , Pan Zhang <sup>1</sup> , Wei Wang <sup>1,3</sup> , <sup>1</sup> Peking University

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